

**RESPONSE UNDER 37 C.F.R.
§1.116 EXPEDITED PROCEDURE
EXAMINING GROUP 1792**

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s): Kwang Choe et al.

Examiner: Padgett, Marianne L.

Serial No.: 10/674,648

Docket No: YOR920030294US1(16817)

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Group Art Unit: 1792

Title: SOI BY OXIDATION OF
POROUS SILICON

Date: May 14, 2008

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Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

*A.L.H. 6/10/08
ANE-I
Entered per REC
dated 6/4/08*

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Sir:

In response to the Final Rejection dated March 14, 2008, please enter the following
remarks and amendments as a matter of record in the above-identified application.

Amendments to the Claims are reflected in the listing of claims, which begin on page 2 of this
paper.

Remarks begin on page 6 of this paper.

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Dated: May 14, 2008


Harry A. Hild Jr.